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(54) **Etching process for zirconium metallic objects.**

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Description

The present invention relates to a process for etching metallic objects formed from zirconium or a zirconium alloy and specifically to a process for determining when an etching bath should be regenerated.

Zirconium components are especially preferred in nuclear reactor systems such as nuclear fuel cladding. As described in my co-pending application Serial No. 888,293 filed July 22, 1986, assigned to the assignee of the present invention, zirconium alloy tubes are pilgered to reduce the size thereof, and are subsequently etched to remove defects from the tubing surface. The preferred zirconium alloys for use in nuclear fuel cladding include Zircaloy-2 and Zircaloy-4. An aqueous hydrofluoric acid - nitric acid etching bath is the preferred etching medium. It is known that the etching rate of such an aqueous bath decreases with use, upon dissolution of zirconium into the bath, until a limiting rate of about 20 percent of the fresh or initial bath is reached. At such a stage, the used or spent bath, which will generally contain about 24g/l of dissolved zirconium alloy was discarded. The spent bath was treated to render it disposable before being discarded. The spent bath contains, among other components, various zirconium compounds or complexes, some tin components when Zircaloy is etched, and residual hydrofluoric and nitric acids.

In order for an operator to know when an etching bath is spent to the extent that the same should be either regenerated or discarded, the dissolved zirconium content of the bath must be determined. One method of determining the dissolved zirconium content of an etching bath is to remove a sample of the bath and analyze the same in a laboratory to ascertain the zirconium content, a time consuming and costly process. Other faster and less costly procedures have been proposed, but as described in published German Patent Disclosure No. 28 28 547, the determination of zirconium metal content in hydrofluoric acid containing etching baths by calorimetric or titrimetric methods is not feasible. In said German patent disclosure, the zirconium content of a hydrofluoric acid - nitric acid etching bath is determined by drawing off a portion of the bath, precipitating the metal in the portion in a form of a difficult to dissolve compound, and determining the concentration of the difficult to dissolve compound in a diluting agent by measuring the turbidity thereof. The preferred precipitating agent is a solution of caustic soda which precipitates the zirconium in the form of zirconium hydroxide, and water to adjust to the necessary dilution.

It is an object of the present invention to provide an efficient and economical process for determining the zirconium metal content of a hydrofluoric acid - nitric acid zirconium metal etching bath.

With this object in view, the present invention resides in a process for etching of zirconium metallic articles with determination of the dissolved zirconium metal content of the bath during the etching process, as defined in claim 1 and as further characterized in subclaims 2 and 3, and, similarly, in a process of determining the dissolved zirconium content of an etching bath for zirconium metal objects as defined in claim 4 and as further charaterized in subclaim 5.

As mentioned hereinbefore, the process according to the invention makes use of the rise in temperature caused by the etch reaction in the etching solution. This phenomena is known per se from document NL-A-6 515 842 disclosing a process for manufacturing semiconductor slices in which a surface layer with predetermined thickness is removed by treatement in an etchant, wherein the same number of slices with identical dimensions is being etched in the same volume of etchant in each turn and the change of temperature of the etchant caused by the etch reaction is chosen as an indication that the required amount of material has been removed. The appropriate change of temperature of the etchant is determined empirically.

In the process according to the invention, an initial determination is made of the rise in temperature of a predetermined volume of the aqueous etching bath upon immersion of a known quantity of a zirconium article, having a known surface area, therein, over a known period of time, as a function of the dissolved zirconium content of the bath. After this determination is made, the dissolved zirconium content of the bath at various times during an etching process is determined by immersing a known quantity of a zirconium metal object having a known surface area into a portion of the bath having the predetermined volume, measuring the rise in temperature of the bath portion over a predetermined time period, and then determining the dissolved zirconium metal content of the bath as a function of the rise in temperature.

Preferably, only a small volume of the bath is used by separating or otherwise segregating the predetermined volume from the bulk of the bath, and immersing the zirconium metal object therein while stirring the bath portion and measuring the temperature rise by use of a thermocouple immersed in the bath portion.

The invention will become more readily apparent from the following description and the accompanying drawings, wherein:

Figure 1 is a graphic illustration showing the proportionality of the temperature rise to weight of Zircaloy-4 in an aqueous HF-HNO_3 etching bath;

Figure 2 is a graphic illustration showing the decrease in etching rate versus loading of dissolved zirconium content of an aqueous HF-HNO_3 etching bath;

Figure 3 is a graphic illustration showing the relationship between temperature increase and bath loading of dissolved zirconium content in a aqueous HF-HNO_3 bath; and

Figure 4 is a schematic illustration of an apparatus for use in carrying out the present process.

The present process provides a calorimetric method for determining the loading of zirconium in an etching bath so as to provide an indication of when the bath should be replenished or replaced. The process thus provides a practical method for determining the dissolved zirconium content or loading of aqueous hydrofluoric acid - nitric acid etching baths for nuclear fuel cladding.

In conventional etching of zirconium metal articles, such as Zircaloy-4 nuclear fuel cladding tubing, etching is used for surface polishing and also to increase the inside diameter of the tubing. The articles are etched by being immersed into an aqueous acid bath. Current etching baths for such articles can use horizontal unstirred etching baths that contain an aqueous solution of 2 to 4 percent, preferably 2 or 3 percent, by weight hydrofluoric acid and 12 to 35 percent, preferably 15 percent, by weight nitric acid. The Zircaloy-4 tubes are immersed in the bath for a predetermined period of time, with the immersion duration increased for a given increase of inside diameters of the tubes due to the exhaustion of bath strength with use.

The contact of the zirconium metal article with the etching bath results in dissolution of metallic components, particularly zirconium metal in ionic or complex form, in the bath and hydrofluoric acid and nitric acid are consumed such that the activity of the bath must be either regenerated or the bath discarded and fresh etching solution provided.

The present process comprises a calorimetric method for determining the dissolved zirconium content of an etching bath at any desired time during use of the bath for etching of zirconium metal articles.

An initial determination is made of the rise in temperature of a predetermined volume of the aqueous etching bath upon immersion of a known quantity of a zirconium metal article, having a known surface area, over a known period of time, as a function of the dissolved zirconium content of the acid bath. This information then allows the bath loading to be determined by simple measurement of temperature increase for a given etching time. The dissolved zirconium content of the bath at various times during an etching process can then be determined by immersing a known quantity of a zirconium metal object having the known surface area into a portion of the bath having the predetermined volume and measuring the rise in temperature of the bath portion over a predetermined time period. The dissolved zirconium content of the bath can then be determined as a function of the rise in temperature by comparing the measured rise in temperature of the bath portion having the unknown concentration of zirconium over the predetermined time period with the information initially obtained for baths having a known concentration of zirconium.

The concept of the invention can be illustrated with reference to Figures 1, 2 and 3. A 1-inch (25.4 mm) length of Zircaloy-4 tubing (typically 0.375 inch (9.53 mm) outer diameter and wall thickness of 0.023 inch (0.58 mm)), of known surface area, was immersed in a 40 ml portion of the hydrofluoric acid (2%) - nitric acid (15%) aqueous etching bath. The bath was agitated with a magnetic stirring bar and the temperature rise of the bath portion over a one minute time period was measured. As illustrated in Figure 1, a temperature rise of 1 °C was observed when the dissolved zirconium content of the portion was about 0.012 gms; a rise of about 2 °C corresponded to a content of about 0.028 gms; a rise of about 5 °C corresponded to a content of about 0.072 gms; and a rise of about 6 °C corresponded to a content of about 0.085 gms. The temperature rise is proportional to the weight of zirconium dissolved in the acid bath, with the temperature increase due to the heat of the dissolution reaction, which was determined to be about 2.72 kcal/gm Zircaloy-4 dissolved.

It is known that the etching rate of a hydrofluoric acid - nitric acid bath for zirconium metals decreases as the bath loading or dissolved zirconium content of the bath increases. As described in my aforementioned co-pending application, etch rates of the bath decrease with use until a limiting rate of about 20 percent of the fresh or initial bath is reached. Figure 2 illustrates graphically the etching rate of the previously described Zircaloy-4 sample in a 2% hydrofluoric acid - 15% nitric acid aqueous etching bath versus the loading, or dissolved zirconium content, of the bath. A linear decrease of etch rate with loading of 0.241 (mgs zirconium to be dissolved/min cm^2 zirconium metal object)/(gm dissolved zirconium/liter bath) was observed. It can be further understood from Figure 2, that by the time that the acid bath contains about 24 gm dissolved zirconium per liter of bath, the etch rate of the bath is only about 0.5mgs zirconium/min cm^2 zirconium metal object. This

rate is so slow that the acid bath should be rejuvenated when the bath loading reaches the level of 24 gm dissolved zirconium per liter of bath.

From a combination of Figures 1 and 2, it can be seen that, as illustrated in Figure 3, the rise in temperature (T°C/Min.) of the acid bath when the previously described Zircaloy-4 sample is immersed therein is inversely proportional to the acid bath loading, grams per liter (g/l). Further from Figure 3, it can readily be seen that the unknown zirconium concentration of an acid bath can be determined by first immersing several of the previously described Zircaloy-4 samples in separate acid baths of various known zirconium concentrations for a minute and measuring the temperature rise of the baths at the end of that minute. Another of the previously described Zircaloy-4 samples is then immersed in the acid bath of unknown zirconium concentration for a minute and the temperature rise after one minute can be compared with the previously determined temperature rise after one minute of baths of known zirconium concentration to determine the unknown zirconium concentration of the acid bath having the unknown zirconium concentration.

The zirconium concentration of the acid bath can be determined in this way several times during the etching process until the zirconium concentration of the bath is such that the bath needs to be rejuvenated.

The present process is useful in etching of articles, such a nuclear fuel cladding, that are composed of zirconium or a zirconium alloy such as Zircaloy-2 or Zircaloy-4. The alloy Zircaloy-2 contains, by weight, about 1.2 to 1.7 percent tin, 0.07 to 0.20 percent iron, 0.05 to 0.15 percent chromium, and about 0.03 to 0.08 percent nickel, the balance being zirconium, while Zircaloy-4 contains, by weight, about 1.2 to 1.7 percent tin, 0.12 to 0.18 percent iron, and 0.05 to 0.15 percent chromium, the balance being zirconium.

The etching process is effected at atmospheric pressure and ambient temperature, although upon exothermic reaction of the acids and the metal, an increase in bath temperature will result. Temperatures of between about 20°C and 50°C are generally used.

Generally, only a small volume of the acid bath of unknown zirconium ion concentration needs to be tested, by separating or otherwise segregating the predetermined volume of the acid bath from the bulk of the acid bath, and immersing the zirconium object therein while stirring the acid bath portion and measuring the temperature rise by use of a thermocouple immersed in the bath portion.

A test of the present invention was effected on a plant scale etching system. During the plant test, a sample of spent etch bath was measured using the present calorimetric method to determine the zirconium content of the bath. The etching bath contained about 500 gallons (1893 l) of aqueous nitric acid - hydrofluoric acid solution (2%HF - 15%HNO_3), and was used to etch final-size Zircaloy-4 fuel cladding. The tube lengths were about 12 feet (3.66 m). The etching was carried out on successive lots of these tubes until the bath was judged to be exhausted by the operator based on experience with the immersion time required to achieve a required size reduction. A 40ml sample of the spent bath was removed and showed a temperature increase of 0.4°C after a one inch (25.4 mm) length of final-size Zircaloy-4 tubing was immersed in the sample, with the sample stirred, for one minute duration. A comparison of the data of Figure 3 showed that this temperature rise indicates the bath loading to be 24g/l. This value confirms to expectations based on previous experience using such etching baths.

A schematic illustration of an apparatus 1 for carrying out the present process is illustrated in Figure 4. A vessel 3, such as a plastic container, is disposed on a magnetic stirrer 5, for receipt of a predetermined volume of an acid bath 7, from a vat containing an existing etching bath, the zirconium content of which is to be measured. A plastic coated magnetic stirring bar 8 is placed in the bath, and a thermocouple 9 inserted into the bath which is connected to a thermocouple detector 11 for temperature readings. A plastic support 13 extends from a base (not shown) to a location within the bath 7. A known quantity of zirconium metal 15, having a known surface area, is suspended on the plastic support 13 within the bath and the bath agitated by actuation of the magnetic stirrer 5 and movement of the magnetic stirring bar 8. The temperature rise of the bath 7 over a predetermined time period, such as a minute, is measured. This temperature rise is then used to determine the zirconium content of the acid bath. The thermocouple detector 11, as illustrated may be associated with a control system 17, that will determine the amount of fresh acid to be added to the existing etching bath to regenerate the same.

The present process thus provides a calorimetric measurement and control of an etching process, a simple, direct, and inexpensive process to provide production control measurements for etching operations. The process provides for on-line detection of bath loading and etching rates and forms the basis for production control systems.

Claims

1. A process for etching of zirconium metallic articles formed from zirconium or a zirconium alloy, wherein said zirconium metallic articles

are contacted with a bath (7) of aqueous hydrofluoric acid - nitric acid etching solution in a tank, wherein the dissolved zirconium metal content of the bath is determined during the etching process as an indication whether the etching solution is spent, characterized in that:
initially the rate of the rise in temperature of a predetermined volume of fresh etching solution is determined upon immersion of a known quantity of said zirconium metal (15), having a known surface area, therein, over a known period of time as a function of the dissolved zirconium content of said bath (7);
later during said etching process a known quantity of a zirconium metal object (15), having a known surface area is immersed into a sample of used etching solution from said bath (7) having said predetermined volume;
the rate of the rise in temperature of said bath sample due to dissolution of said zirconium metal object (15) therein is measured over a predetermined period of time;
and the dissolved zirconium metal content of said bath (7) is determined as a function of said rate of rise of temperature of said bath sample.

2. The process of claim 1, characterized in that said sample of said bath (7) is removed from said bath (7) and transferred to a vessel (3) wherein said rise in temperature is measured.

3. The process of claim 1 or 2, characterized in that said bath (7) is treated by regenerating the same and further etching of zirconium metallic articles effected in said regenerated bath.

4. A process of determining the dissolved zirconium content of an aqueous hydrofluoric acid - nitric acid etching bath (7) for zirconium metal objects characterized by:
determining the rate of rise in temperature of a predetermined volume of a fresh bath (7) upon immersion of a known quantity of said zirconium metal (15) having a known surface area therein over a known period of time, as a function of the dissolved zirconium content of said bath (7);
after some time of use of said bath, immersing a known quantity of a zirconium metal object (15), having a known surface area, into a sample of said bath (7), having said predetermined volume;
measuring the rise in temperature of said bath portion (7) due to dissolution of said zirconium metal object (15) therein over a predetermined period of time; and
determining the dissolved zirconium metal content of said bath (7) as a function of said rise of temperature of said bath portion (7).

5. The process of claim 4, characterized in that said sample is removed from said used bath (7) and transferred to a vessel (3) wherein said measuring is effected.

Patentansprüche

1. Verfahren zum Ätzen von Zirkoniummetallgegenständen aus Zirkonium oder einer Zirkoniumlegierung, wobei die Zirkoniummetallgegenstände mit einem Bad (7) aus wäßriger Fluorwasserstoffsäure-Salpetersäure-Ätzlösung in einem Tank in Berührung gebracht werden, wobei der aufgelöste Zirkoniummetallgehalt des Bades während des Ätzvorgangs als Anzeige dafür bestimmt wird, die Ätzlösung verbraucht ist, dadurch gekennzeichnet, daß:
anfänglich die Temperaturanstiegsgeschwindigkeit in einem vorgegebenen Volumen frischer Ätzlösung nach Eintauchen einer bekannten Menge des Zirkoniummetalls (15) mit bekannter Oberfläche während einer gegebenen Zeitspanne als Funktion des aufgelösten Zirkoniumgehalts in dem Bad (7) bestimmt wird;
später während des Ätzvorgangs eine bekannte Menge eines Zirkoniummetallgegenstands (15) mit bekannter Oberfläche in eine Probe der benutzten Ätzlösung aus dem Bad (7) mit dem vorgegebenen Volumen eingetaucht wird;
die Temperaturanstiegsgeschwindigkeit in der Badprobe aufgrund der Auflösung des Zirkoniummetallgegenstands (15) darin über eine vorgegebene Zeitspanne gemessen wird;
und der aufgelöste Zirkoniummetallgehalt des Bades (7) als Funktion der Temperaturanstiegsgeschwindigkeit in der Badprobe bestimmt wird.

2. Verfahren nach Anspruch 1, dadurch gekennzeichnet, daß die Probe des Bads (7) aus dem Bad (7) entnommen und in ein Gefäß (3) übertragen wird, in welchem der Temperaturanstieg gemessen wird.

3. Verfahren nach Anspruch 1 oder 2, dadurch gekennzeichnet, daß das Bad durch Regenerieren desselben behandelt wird und ein weiteres Ätzen von Zirkoniummetallgegenständen in dem regenerierten Bad stattfindet.

4. Verfahren zur Bestimmung des aufgelösten Zirkoniumgehalts eines wäßrigen Fluorwasserstoffsäure-Salpetersäure-Ätzbades (7) für Zirkoniummetallgegenstände, gekenn-

zeichnet durch:
Bestimmen der Temperaturgeschwindigkeit in einem vorgegebenen Volumen eines frischen Bades (7) beim Eintauchen einer bekannten Menge des Zirkoniummetalls (15) mit bekannter Oberfläche während einer bekannten Zeitspanne als Funktion des aufgelösten Zirkoniumgehalts des Bades (7);
nach gewisser Benutzungsdauer des Bades Eintauchen einer bekannten Menge eines Zirkoniummetallgegenstandes (15) mit bekannter Oberfläche in eine Probe des Bades (7) mit dem vorgegebenen Volumen;
Messen des Temperaturanstiegs in der Badprobe (7) aufgrund der Auflösung des Zirkoniummetallgegenstands (15) darin während einer vorgegebenen Zeitspanne; und
Bestimmen des aufgelösten Zirkoniummetallgehalts des Bades (7) als Funktion des Temperaturanstiegs der Badprobe (7).

5. Verfahren nach Anspruch 4, dadurch gekennzeichnet, daß die Probe aus dem benützten Bad (7) entnommen und in ein Gefäß (3) übertragen wird, in welchem die Messung stattfindet.

Revendications

1. Procédé de décapage chimique d'objets métalliques au Zirconium, faits de zirconium ou d'un alliage de zirconium, dans lequel lesdits objets métalliques au zirconium sont mis en contact avec un bain (7) de solution d'attaque, acide nitrique/acide fluorhydrique aqueux, contenu dans un réservoir, dans lequel on détermine la teneur du bain en métal zirconium dissout pendant le traitement de décapage comme indication du fait que la solution d'attaque est épuisée, caractérisé en ce que:
- on détermine au départ la vitesse de montée en température d'un volume prédéterminé de solution d'attaque fraîche lors de l'immersion dans celle-ci d'une quantité connue dudit métal zirconium (15), de superficie connue et sur un laps de temps connu, comme une fonction de la teneur dudit bain (7) en zirconium dissout;
- on immerge ensuite, pendant ledit traitement de décapage, une quantité connue d'objets (15) en métal zirconium, de superficie connue, dans un échantillon, ayant ledit volume prédéterminé, de la solution d'attaque déjà utilisée en provenance dudit bain (7);
- on mesure sur un laps de temps prédéterminé la vitesse de montée en température dudit échantillon de bain provoquée par la dissolution dans celui-ci dudit objet (15) en métal zirconium;
- et on détermine la teneur dudit bain (7) en métal Zirconium dissout comme une fonction de ladite vitesse de montée en température dudit échantillon de bain.

2. Procédé selon la revendication 1, caractérisé en ce que ledit échantillon dudit bain (7) est retiré dudit bain (7) et transféré dans une cuve (3) dans laquelle on mesure ladite montée en température.

3. Procédé selon la revendication 1 ou 2, caractérisé en ce que l'on traite ledit bain (7) en le régénérant et on poursuit le décapage desdits objets métalliques au zirconium dans ledit bain régénéré.

4. Procédé pour déterminer la teneur en zirconium dissout d'un bain (7) de décapage à l'acide nitrique/acide fluorhydrique aqueux destiné à des objets métalliques au zirconium, caractérisé par:
- la détermination de la vitesse de montée en température d'un volume prédéterminé d'un bain frais (7) lors de l'immersion dans celui-ci d'une quantité connue dudit métal zirconium (15), avec une superficie connue et sur un laps de temps connu, comme une fonction de la teneur dudit bain (7) en zirconium dissout;
- l'immersion, après un certain temps d'utilisation dudit bain, d'une quantité connue d'un objet (15) en métal zirconium, de superficie connue, dans un échantillon dudit bain (7) ayant ledit volume prédéterminé;
- la mesure de la montée en température dudit échantillon de bain (7) provoquée par la dissolution dans celui-ci dudit objet (15) en métal zirconium sur un laps de temps prédéterminé; et
- la détermination de la teneur dudit bain (7) en métal zirconium dissout comme une fonction de ladite montée en température dudit échantillon de bain (7).

5. Procédé selon la revendication 4, caractérisé en ce que ledit échantillon est retiré dudit bain (7) déjà utilisé et transféré dans une cuve (3) dans laquelle est effectuée ladite mesure.

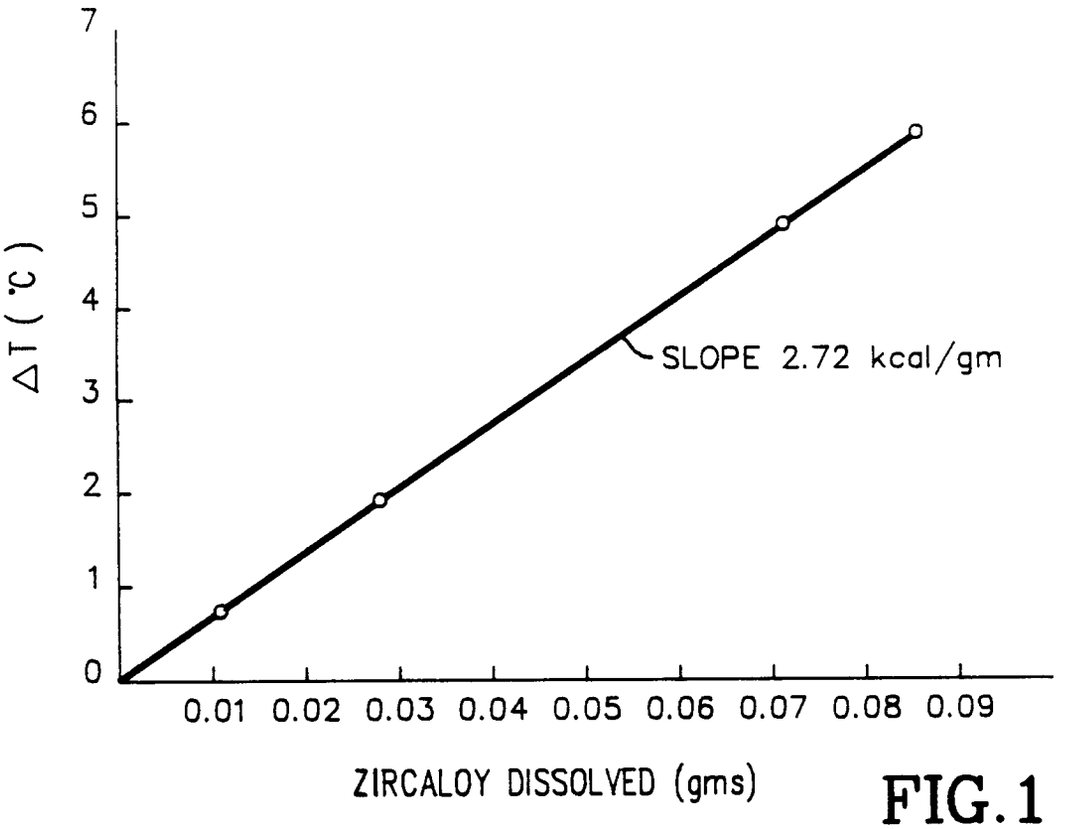
7
6
5
4
3
2
1
0
ΔT (°C)
SLOPE 2.72 kcal/gm
0.01 0.02 0.03 0.04 0.05 0.06 0.07 0.08 0.09
ZIRCALOY DISSOLVED (gms)

FIG. 1

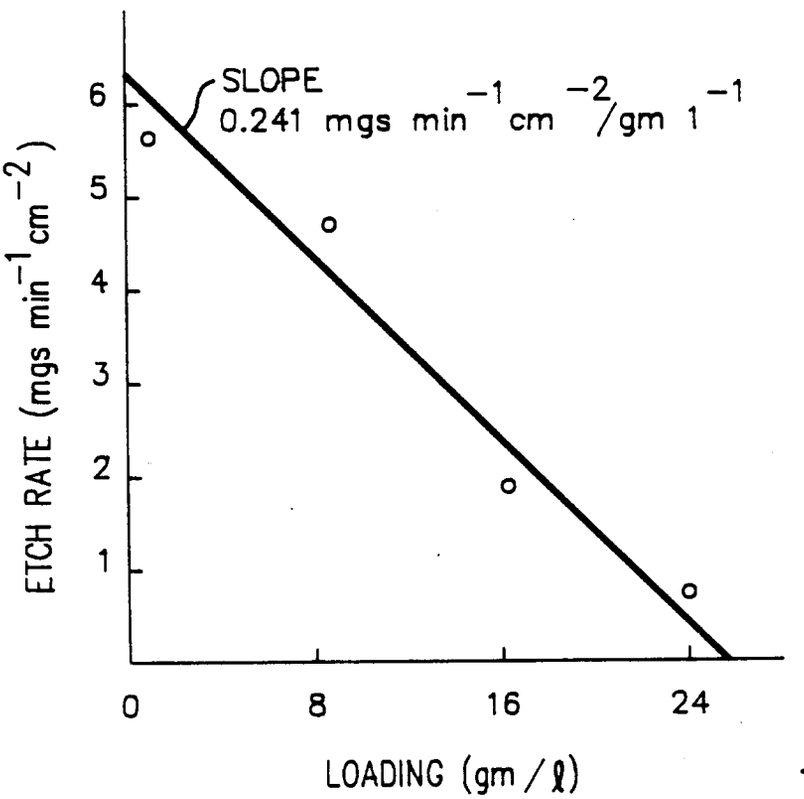
SLOPE
0.241 mgs min⁻¹ cm⁻² /gm l⁻¹
6
5
4
3
2
1
ETCH RATE (mgs min⁻¹cm⁻²)
0
8
16
24
LOADING (gm / ℓ)

FIG. 2

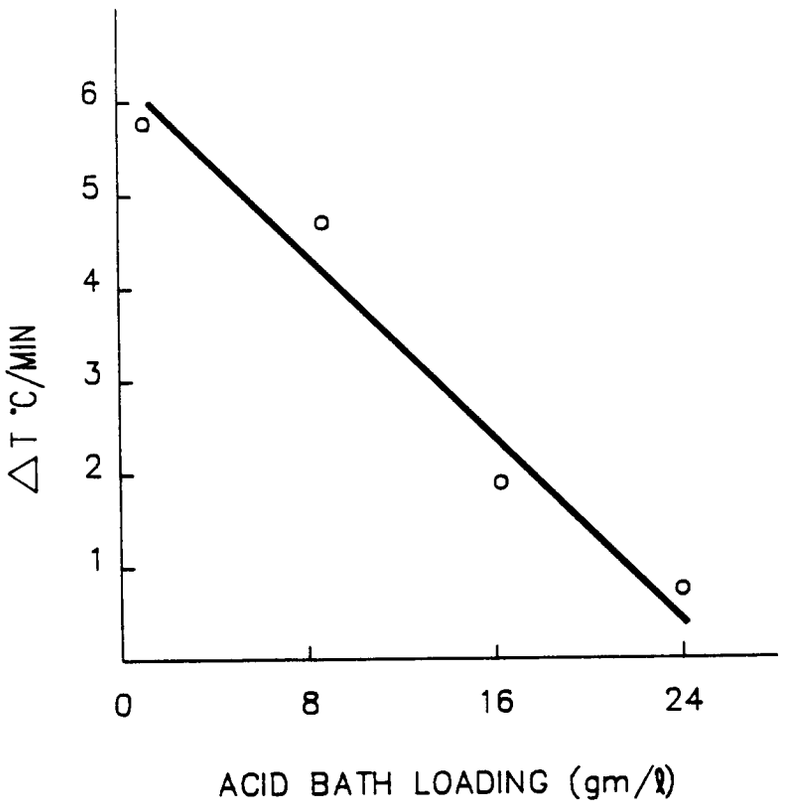
6
5
4
3
2
1
ΔT °C/MIN
0
8
16
24
ACID BATH LOADING (gm/ℓ)

FIG. 3

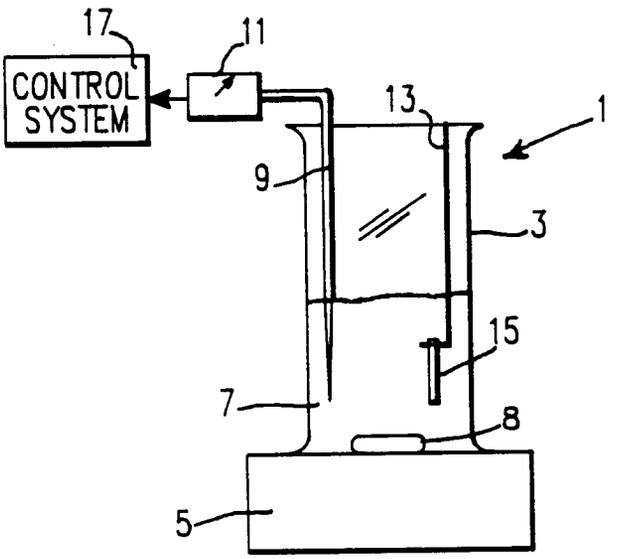
17
CONTROL SYSTEM
11
13
1
9
3
15
7
8
5

FIG. 4